

SLOVENSKI STANDARD SIST EN 61788-17:2013

01-julij-2013

Superprevodnost - 17. del: Meritve elektronskih karakteristik - Krajevno kritična tokovna gostota in njena porazdelitev po površinsko obširnih razsežnih superprevodnih plasteh

Superconductivity - Part 17: Electronic characteristic measurements - Local critical current density and its distribution in large-area superconducting films

Supraleitfähigkeit - Teil 17: Messungen der elektronischen Charakteristik - Lokale kritische Stromdichte und deren Verteilung in großflächigen supraleitenden Schichten (standards.iteh.ai)

Supraconductivité - Partie 17: Mesur<u>es de caractéristi</u>gues électroniques - Densité de courant critique local et sa distribution dans les films supraconducteurs de grande surface 3e623218c76d/sist-en-61788-17-2013

Ta slovenski standard je istoveten z: EN 61788-17:2013

<u>ICS:</u>

17.220.20	Merjenje električnih in magnetnih veličin	Measurement of electrical and magnetic quantities
29.050	Superprevodnost in prevodni materiali	Superconductivity and conducting materials

SIST EN 61788-17:2013

en



iTeh STANDARD PREVIEW (standards.iteh.ai)

SIST EN 61788-17:2013

EUROPEAN STANDARD NORME EUROPÉENNE EUROPÄISCHE NORM

EN 61788-17

April 2013

ICS 17.220.20; 29.050

English version

Superconductivity -Part 17: Electronic characteristic measurements -Local critical current density and its distribution in large-area superconducting films

(IEC 61788-17:2013)

Supraconductivité -Partie 17: Mesures de caractéristiques électroniques -Densité de courant critique local et sa distribution dans les films supraconducteurs de grande surface (CEI 61788-17:2013) **Supraleitfähigkeit -**Teil 17: Messungen der elektronischen Charakteristik -Lokale kritische Stromdichte und deren Verteilung in großflächigen supraleitenden Schichten (IEC 61788-17:2013) **(standards.iteh.ai)**

> <u>SIST EN 61788-17:2013</u> https://standards.iteh.ai/catalog/standards/sist/c2a702e4-e4f9-4d17-b13f-3e623218c76d/sist-en-61788-17-2013

This European Standard was approved by CENELEC on 2013-02-20. CENELEC members are bound to comply with the CEN/CENELEC Internal Regulations which stipulate the conditions for giving this European Standard the status of a national standard without any alteration.

Up-to-date lists and bibliographical references concerning such national standards may be obtained on application to the CEN-CENELEC Management Centre or to any CENELEC member.

This European Standard exists in three official versions (English, French, German). A version in any other language made by translation under the responsibility of a CENELEC member into its own language and notified to the CEN-CENELEC Management Centre has the same status as the official versions.

CENELEC members are the national electrotechnical committees of Austria, Belgium, Bulgaria, Croatia, Cyprus, the Czech Republic, Denmark, Estonia, Finland, Former Yugoslav Republic of Macedonia, France, Germany, Greece, Hungary, Iceland, Ireland, Italy, Latvia, Lithuania, Luxembourg, Malta, the Netherlands, Norway, Poland, Portugal, Romania, Slovakia, Slovenia, Spain, Sweden, Switzerland, Turkey and the United Kingdom.

CENELEC

European Committee for Electrotechnical Standardization Comité Européen de Normalisation Electrotechnique Europäisches Komitee für Elektrotechnische Normung

Management Centre: Avenue Marnix 17, B - 1000 Brussels

© 2013 CENELEC - All rights of exploitation in any form and by any means reserved worldwide for CENELEC members.

Ref. No. EN 61788-17:2013 E

Foreword

The text of document 90/310/FDIS, future edition 1 of IEC 61788-17, prepared by IEC TC 90, "Superconductivity" was submitted to the IEC-CENELEC parallel vote and approved by CENELEC as EN 61788-17:2013.

The following dates are fixed:

•	latest date by which the document has to be implemented at national level by publication of an identical national standard or by endorsement	(dop)	2013-11-20
•	latest date by which the national standards conflicting with the document have to be withdrawn	(dow)	2016-02-20

Attention is drawn to the possibility that some of the elements of this document may be the subject of patent rights. CENELEC [and/or CEN] shall not be held responsible for identifying any or all such patent rights.

iTeh STEndorsement notice VIEW

The text of the International Standard JEC 61788-17:2013 was approved by CENELEC as a European Standard without any modification.

Annex ZA

(normative)

Normative references to international publications with their corresponding European publications

The following documents, in whole or in part, are normatively referenced in this document and are indispensable for its application. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

NOTE When an international publication has been modified by common modifications, indicated by (mod), the relevant EN/HD applies.

Publication	<u>Year</u>	<u>Title</u>	<u>EN/HD</u>	<u>Year</u>
IEC 60050	Series	International electrotechnical vocabulary	-	-

iTeh STANDARD PREVIEW (standards.iteh.ai)



iTeh STANDARD PREVIEW (standards.iteh.ai)



Edition 1.0 2013-01

INTERNATIONAL STANDARD

NORME INTERNATIONALE



Superconductivity Teh STANDARD PREVIEW

Part 17: Electronic characteristic measurements – Local critical current density and its distribution in large-area superconducting films

SIST EN 61788-17:2013

Supraconductivités #standards.iteh.ai/catalog/standards/sist/c2a702e4-e4f9-4d17-b13f-

Partie 17: Mesures de caractéristiques électroniques – Densité de courant critique local et sa distribution dans les films supraconducteurs de grande surface

INTERNATIONAL ELECTROTECHNICAL COMMISSION

COMMISSION ELECTROTECHNIQUE INTERNATIONALE

PRICE CODE CODE PRIX



ICS 17.220.20; 29.050

ISBN 978-2-83220-583-9

Warning! Make sure that you obtained this publication from an authorized distributor. Attention! Veuillez vous assurer que vous avez obtenu cette publication via un distributeur agréé.

 Registered trademark of the International Electrotechnical Commission Marque déposée de la Commission Electrotechnique Internationale

CONTENTS

- 2 -

FOREWORD4			
INT	INTRODUCTION		
1	Scope		
2	Norm	native reference	8
3	Terms and definitions		
4	Requ	uirements	9
5	Арра	aratus	9
	5.1	Measurement equipment	9
	5.2	Components for inductive measurements	10
		5.2.1 Coils	10
		5.2.2 Spacer film	11
		5.2.3 Mechanism for the set-up of the coil	11
•		5.2.4 Calibration wafer	
6	Meas	surement procedure	12
	6.1	General	
	6.2	Determination of the experimental coil coefficient	
		6.2.2 Transport measurements of bridgen in the polihection water	12
		6.2.3 <i>II</i> measurements of the calibration water	
		6.2.4 Calculation of the <i>E</i> - <i>l</i> characteristics from frequency-dependent	
		data	····
		6.2.5 Determination of the κ from J_{ct} and J_{c0} values for an appropriate	e <i>E</i> 14
	6.3	Measurement of J_c in sample films sit-en-61788-17-2013	15
	6.4	Measurement of J_{c} with only one frequency	15
_	6.5	Examples of the theoretical and experimental coil coefficients	
7	Unce	ertainty in the test method	17
	7.1	Major sources of systematic effects that affect the U_3 measurement	
	7.2	Effect of deviation from the prescribed value in the coil-to-film distance .	
	7.3 7.4	Uncertainty of the experimental coll coefficient and the obtained J_c	
	7.4 7.5	Specimen protection	
8	Test	report	
•	8 1	Identification of test specimen	19
	8.2	Report of J_{2} values	
	8.3	Report of test conditions	
Anr	nex A	(informative) Additional information relating to Clauses 1 to 8	20
Anr	nex B	(informative) Optional measurement systems	26
Annex C (informative) Uncertainty considerations			
Annex D (informative) Evaluation of the uncertainty			
Bib	liograi	phy	43
		F · · J · · · · ·	
Fia	ure 1.	- Diagram for an electric circuit used for inductive J measurement of HI	rs
film	S		
	_		

 61788-17 © IEC:2013

Figure 4 – Illustration for the sample coil and the magnetic field during measurement	13
Figure 5 – E - J characteristics measured by a transport method and the U_3 inductive method	14
Figure 6 –Example of the normalized third-harmonic voltages (U_3/fl_0) measured with various frequencies	15
Figure 7 – Illustration for coils 1 and 3 in Table 1	16
Figure 8 – The coil-factor function $F(r) = 2H_0/I_0$ calculated for the three coils	17
Figure 9 – The coil-to-film distance Z_1 dependence of the theoretical coil coefficient k	18
Figure A.1 – Illustration for the sample coil and the magnetic field during measurement	22
Figure A.2 – (a) U_3 and (b) U_3/I_0 plotted against I_0 in a YBCO thin film measured in applied DC magnetic fields, and the scaling observed when normalized by I_{th} (insets)	23
Figure B.1 – Schematic diagram for the variable-RL-cancel circuit	27
Figure B.2 – Diagram for an electrical circuit used for the 2-coil method	27
Figure B.3 – Harmonic noises arising from the power source	28
Figure B.4 – Noise reduction using a cancel coil with a superconducting film	28
Figure B.5 – Normalized harmonic noises (U_3/fl_0) arising from the power source	29
Figure B.6 – Normalized noise voltages after the reduction using a cancel coil with a superconducting film	29
Figure B.7 – Normalized noise voltages after the reduction using a cancel coil without a superconducting film	30
Figure B.8 – Normalized noise voltages with the 2-coil system shown in Figure B.2	30
Figure D.1 – Effect of the coil position against a superconducting thin film on the measured J_c values	41
https://standards.iteh.ai/catalog/standards/sist/c2a702e4-e4f9-4d17-b13f-	
Table 1 – Specifications and collecterificients of typical sample colls	16
Table C.1 – Output signals from two nominally identical extensioneters	33
Table C.2 – Mean values of two output signals	33
Table C.3 – Experimental standard deviations of two output signals	33
Table C.4 – Standard uncertainties of two output signals	34
Table C.5 – Coefficient of variations of two output signals	34
Table D.1 – Uncertainty budget table for the experimental coil coefficient k'	37
Table D.2 – Examples of repeated measurements of J_c and <i>n</i> -values	40

INTERNATIONAL ELECTROTECHNICAL COMMISSION

SUPERCONDUCTIVITY -

Part 17: Electronic characteristic measurements – Local critical current density and its distribution in large-area superconducting films

FOREWORD

- 1) The International Electrotechnical Commission (IEC) is a worldwide organization for standardization comprising all national electrotechnical committees (IEC National Committees). The object of IEC is to promote international co-operation on all questions concerning standardization in the electrical and electronic fields. To this end and in addition to other activities, IEC publishes International Standards, Technical Specifications, Technical Reports, Publicly Available Specifications (PAS) and Guides (hereafter referred to as "IEC Publication(s)"). Their preparation is entrusted to technical committees; any IEC National Committee interested in the subject dealt with may participate in this preparatory work. International, governmental and non-governmental organizations liaising with the IEC also participate in this preparation. IEC collaborates closely with the International Organization for Standardization (ISO) in accordance with conditions determined by agreement between the two organizations.
- The formal decisions or agreements of IEC on technical matters express, as nearly as possible, an international consensus of opinion on the relevant subjects since each technical committee has representation from all interested IEC National Committees.
- 3) IEC Publications have the form of recommendations for international use and are accepted by IEC National Committees in that sense. While all reasonable efforts are made to ensure that the technical content of IEC Publications is accurate, IEC cannot be held responsible for the way in which they are used or for any misinterpretation by any end user.
- 4) In order to promote international uniformity, IEC National Committees undertake to apply IEC Publications transparently to the maximum extent possible in 6their hational and regional publications. Any divergence between any IEC Publication and the corresponding national or regional publication shall be clearly indicated in the latter. 3e623218c76d/sist-en-61788-17-2013
- 5) IEC itself does not provide any attestation of conformity. Independent certification bodies provide conformity assessment services and, in some areas, access to IEC marks of conformity. IEC is not responsible for any services carried out by independent certification bodies.
- 6) All users should ensure that they have the latest edition of this publication.
- 7) No liability shall attach to IEC or its directors, employees, servants or agents including individual experts and members of its technical committees and IEC National Committees for any personal injury, property damage or other damage of any nature whatsoever, whether direct or indirect, or for costs (including legal fees) and expenses arising out of the publication, use of, or reliance upon, this IEC Publication or any other IEC Publications.
- 8) Attention is drawn to the Normative references cited in this publication. Use of the referenced publications is indispensable for the correct application of this publication.

International Standard IEC 61788-17 has been prepared by IEC technical committee 90: Superconductivity.

The text of this standard is based on the following documents:

FDIS	Report on voting
90/310/FDIS	90/319/RVD

Full information on the voting for the approval of this standard can be found in the report on voting indicated in the above table.

This publication has been drafted in accordance with the ISO/IEC Directives, Part 2.

A list of all the parts of the IEC 61788 series, published under the general title *Superconductivity*, can be found on the IEC website.

61788-17 © IEC:2013

The committee has decided that the contents of this publication will remain unchanged until the stability date indicated on the IEC web site under "http://webstore.iec.ch" in the data related to the specific publication. At this date, the publication will be

- reconfirmed,
- withdrawn,
- replaced by a revised edition, or
- amended.

IMPORTANT – The 'colour inside' logo on the cover page of this publication indicates that it contains colours which are considered to be useful for the correct understanding of its contents. Users should therefore print this document using a colour printer.

iTeh STANDARD PREVIEW (standards.iteh.ai)

INTRODUCTION

- 6 -

Over twenty years after their discovery in 1986, high-temperature superconductors are now finding their way into products and technologies that will revolutionize information transmission, transportation, and energy. Among them, high-temperature superconducting (HTS) microwave filters, which exploit the extremely low surface resistance of superconductors, have already been commercialized. They have two major advantages over conventional non-superconducting filters, namely: low insertion loss (low noise characteristics) and high frequency selectivity (sharp cut) [1]¹. These advantages enable a reduced number of base stations, improved speech quality, more efficient use of frequency bandwidths, and reduced unnecessary radio wave noise.

Large-area superconducting thin films have been developed for use in microwave devices [2]. They are also used for emerging superconducting power devices, such as, resistive-type superconducting fault-current limiters (SFCLs) [3-5], superconducting fault detectors used for superconductor-triggered fault current limiters [6, 7] and persistent-current switches used for persistent-current HTS magnets [8, 9]. The critical current density J_c is one of the key parameters that describe the quality of large-area HTS films. Nondestructive, AC inductive methods are widely used to measure J_c and its distribution for large-area HTS films [10–13], among which the method utilizing third-harmonic voltages $U_3 \cos(3\omega t + \theta)$ is the most popular [10, 11], where ω , t and θ denote the angular frequency, time, and initial phase, respectively. However, these conventional methods are not accurate because they have not considered the electric-field E criterion of the J_c measurement [14, 15] and sometimes use an inappropriate criterion to determine the threshold current I_{th} from which J_c is calculated [16]. A conventional method can obtain J_c values that differ from the accurate values by 10 % to 20 % [15]. It is thus necessary to establish standard test methods to precisely measure the local critical current density and its distribution, to which all involved in the HTS filter industry can refer for quality control of the HTS films. Background knowledge on the inductive J_c measurements of HTS thin films is summarized in Annex A. SIST EN 61788-17:2013

In these inductive methods, $AC_3magnetic fields are generated with AC currents <math>I_0\cos\omega t$ in a small coil mounted just above the film, and J_c is calculated from the threshold coil current I_{th} , at which full penetration of the magnetic field to the film is achieved [17]. For the inductive method using third-harmonic voltages U_3 , U_3 is measured as a function of I_0 , and the I_{th} is determined as the coil current I_0 at which U_3 starts to emerge. The induced electric fields E in the superconducting film at $I_0 = I_{th}$, which are proportional to the frequency f of the AC current, can be estimated by a simple Bean model [14]. A standard method has been proposed to precisely measure J_c with an electric-field criterion by detecting U_3 and obtaining the *n*-value (index of the power-law *E-J* characteristics) by measuring I_{th} precisely at various frequencies [14, 15, 18, 19]. This method not only obtains precise J_c values, but also facilitates the detection of degraded parts in inhomogeneous specimens, because the decline of *n*-value is more remarkable than the decrease of J_c in such parts [15]. It is noted that this standard method is excellent for assessing homogeneity in large-area HTS films, although the relevant parameter for designing microwave devices is not J_c , but the surface resistance. For application of large-area superconducting thin films to SFCLs, knowledge on J_c distribution is vital, because J_c distribution significantly affects quench distribution in SFCLs during faults.

The International Electrotechnical Commission (IEC) draws attention to the fact that it is claimed that compliance with this document may involve the use of a patent concerning the determination of the E-J characteristics by inductive J_c measurements as a function of frequency, given in the Introduction, Clause 1, Clause 4 and 5.1.

IEC takes no position concerning the evidence, validity and scope of this patent right.

The holder of this patent right has assured the IEC that he is willing to negotiate licenses free of charge with applicants throughout the world. In this respect, the statement of the holder of this patent right is registered with the IEC. Information may be obtained from:

¹ Numbers in square brackets refer to the Bibliography.

61788-17 © IEC:2013

Name of holder of patent right: National Institute of Advanced Industrial Science and Technology

Address:

Intellectual Property Planning Office, Intellectual Property Department 1-1-1, Umezono, Tsukuba, Ibaraki Prefecture, Japan

Attention is drawn to the possibility that some of the elements of this document may be subject to patent rights other than those identified above. IEC shall not be held responsible for identifying any or all such patent rights.

ISO (www.iso.org/patents) and IEC (http://patents.iec.ch) maintain on-line data bases of patents relevant to their standards. Users are encouraged to consult the data bases for the most up to date information concerning patents.

iTeh STANDARD PREVIEW (standards.iteh.ai)

SUPERCONDUCTIVITY -

- 8 -

Part 17: Electronic characteristic measurements – Local critical current density and its distribution in large-area superconducting films

1 Scope

This part of IEC 61788 describes the measurements of the local critical current density (J_c) and its distribution in large-area high-temperature superconducting (HTS) films by an inductive method using third-harmonic voltages. The most important consideration for precise measurements is to determine J_c at liquid nitrogen temperatures by an electric-field criterion and obtain current-voltage characteristics from its frequency dependence. Although it is possible to measure J_c in applied DC magnetic fields [20, 21]², the scope of this standard is limited to the measurement without DC magnetic fields.

This technique intrinsically measures the critical sheet current that is the product of J_c and the film thickness *d*. The range and measurement resolution for $J_c d$ of HTS films are as follows:

- J_cd: from 200 A/m to 32 kA/m (based on results, not limitation).
- Measurement resolution: 100 A/m (based on results, not limitation).

2 Normative reference

SIST EN 61788-17:2013

https://standards.iteh.ai/catalog/standards/sist/c2a702e4-e4f9-4d17-b13f-The following documents, in whole or in parts are normatively referenced in this document and are indispensable for its application. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

IEC 60050 (all parts), *International Electrotechnical Vocabulary* (available at http://www.electropedia.org)

3 Terms and definitions

For the purposes of this document, the definitions given in IEC 60050-815:2000, some of which are repeated here for convenience, apply.

3.1 critical current

I_c

maximum direct current that can be regarded as flowing without resistance

Note 1 to entry: I_c is a function of magnetic field strength and temperature.

[SOURCE: IEC 60050-815:2000, 815-03-01]

² Numbers in square brackets refer to the Bibliography.

3.2 critical current criterion

I_c criterion

criterion to determine the critical current, $I_{\rm c}$, based on the electric field strength, *E* or the resistivity, ρ

Note 1 to entry: $E = 10 \ \mu$ V/m or $E = 100 \ \mu$ V/m is often used as electric field criterion, and $\rho = 10^{-13} \ \Omega$ · m or $\rho = 10^{-14} \ \Omega$ · m is often used as resistivity criterion. (" $E = 10 \$ V/m or $E = 100 \$ V/m" in the current edition is mistaken and is scheduled to be corrected in the second edition).

[SOURCE: IEC 60050-815:2000, 815-03-02]

3.3

critical current density

 $J_{\rm c}$

the electric current density at the critical current using either the cross-section of the whole conductor (overall) or of the non-stabilizer part of the conductor if there is a stabilizer

Note 1 to entry: The overall current density is called in English, engineering current density (symbol: J_e). [SOURCE: IEC 60050-815:2000, 815-03-03]

3.4

transport critical current density

J_{ct}

critical current density obtained by a resistivity or a voltage measurement

[SOURCE: IEC 60050-815:2000 (815-03-04] rds.iteh.ai)

3.5

n-value (of a superconductor) SIST EN 61788-17:2013

exponent obtained tins a specific range of electric field strength 7 or 3 fesistivity when the voltage/current U (I) curve is approximated by the equation $U^{3} \propto I^{n}$

[SOURCE: IEC 60050-815:2000, 815-03-10]

4 Requirements

The critical current density J_c is one of the most fundamental parameters that describe the quality of large-area HTS films. In this standard, J_c and its distribution are measured non-destructively via an inductive method by detecting third-harmonic voltages $U_3\cos(3\omega t+\theta)$. A small coil, which is used both to generate AC magnetic fields and detect third-harmonic voltages, is mounted just above the HTS film and used to scan the measuring area. To measure J_c precisely with an electric-field criterion, the threshold coil currents I_{th} , at which U_3 starts to emerge, are measured repeatedly at different frequencies and the *E-J* characteristics are determined from their frequency dependencies.

The target relative combined standard uncertainty of the method used to determine the absolute value of J_c is less than 10 %. However, the target uncertainty is less than 5 % for the purpose of evaluating the homogeneity of J_c distribution in large-area superconducting thin films.

5 Apparatus

5.1 Measurement equipment

Figure 1 shows a schematic diagram of a typical electric circuit used for the third-harmonic voltage measurements. This circuit is comprised of a signal generator, power amplifier, digital multimeter (DMM) to measure the coil current, band-ejection filter to reduce the fundamental